



Alkali antimonide photocathode performance in ultrafast electron microdiffraction

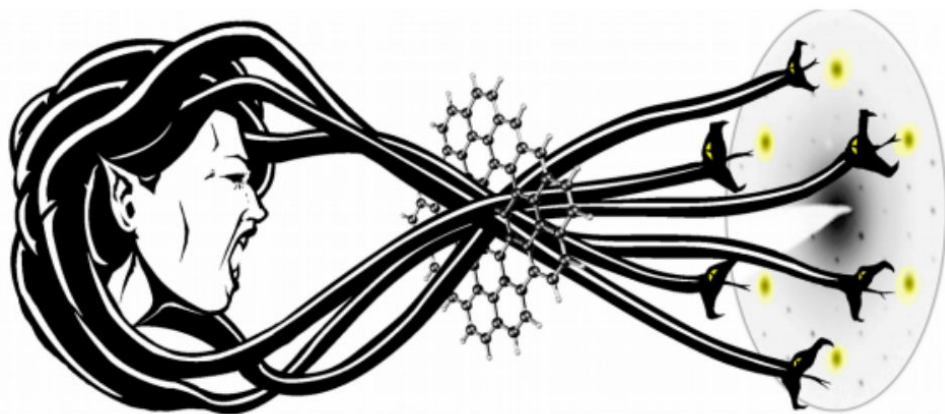
Cameron Duncan and William Li
Cornell University



MEDUSA

- Ultrafast Electron Diffraction (UED) is a time-resolved technique for studying materials out of equilibrium
- Conservation of six-dimensional brightness imposes a trade-off between spatial and temporal resolution in UED
- Machines that deliver 100 fs or shorter electron pulses typically produce rms transverse beamsizes 25 μm or greater
- With a low MTE electron source, we form single micron size probes while maintaining 100s of femtosecond temporal resolution

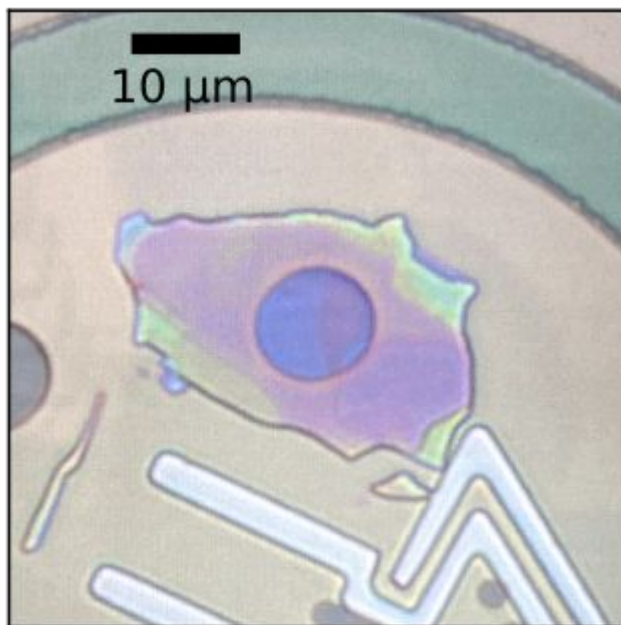
MICRO
ELECTRON
DIFFRACTION FOR
ULTRAFAST
STRUCTURAL
ANALYSIS



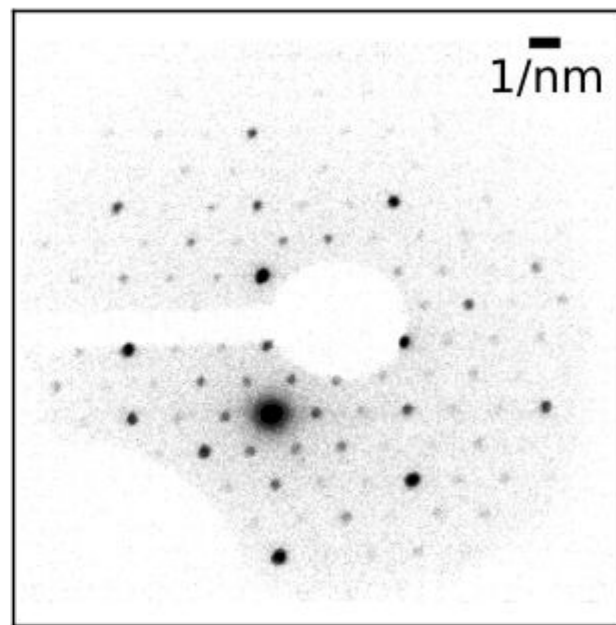


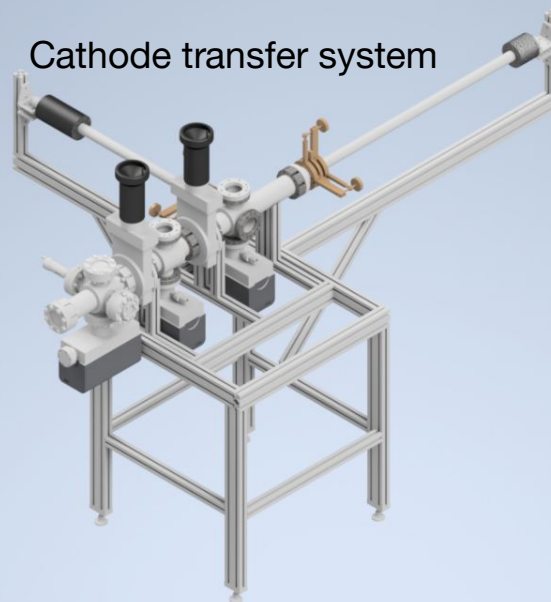
Microdiffraction

- Small probes make possible the study of small samples, e.g., flakes of materials that are challenging to prepare as large single crystals



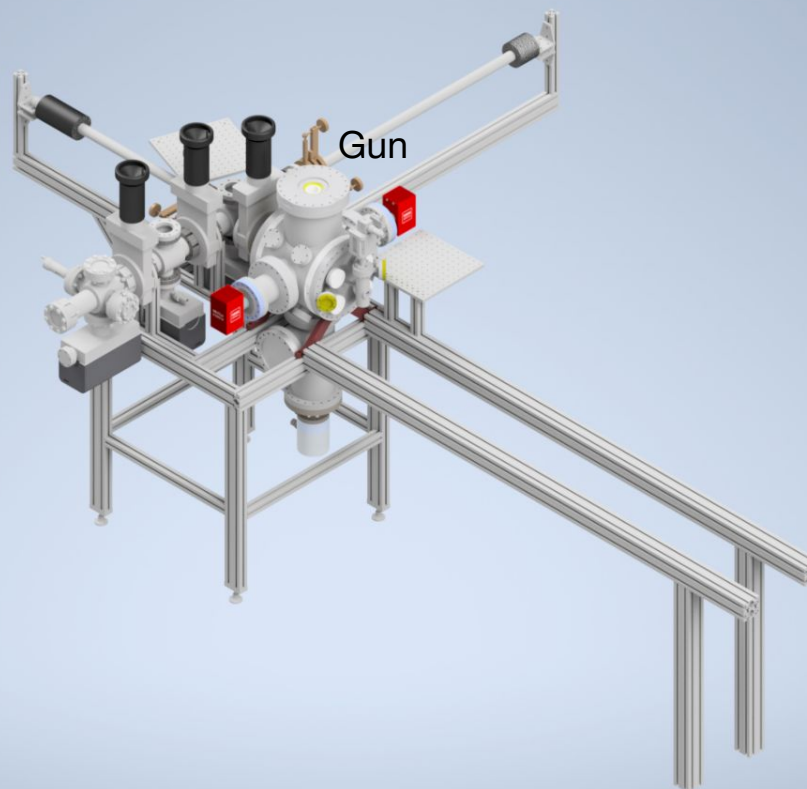
Diffraction sample, Nb_3Br_8





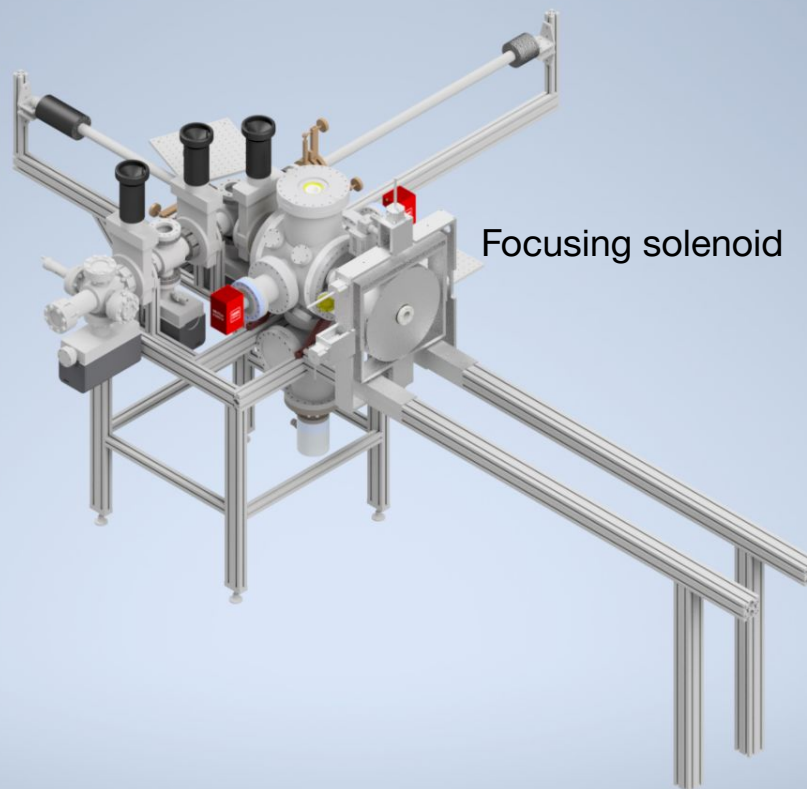


Beamline overview



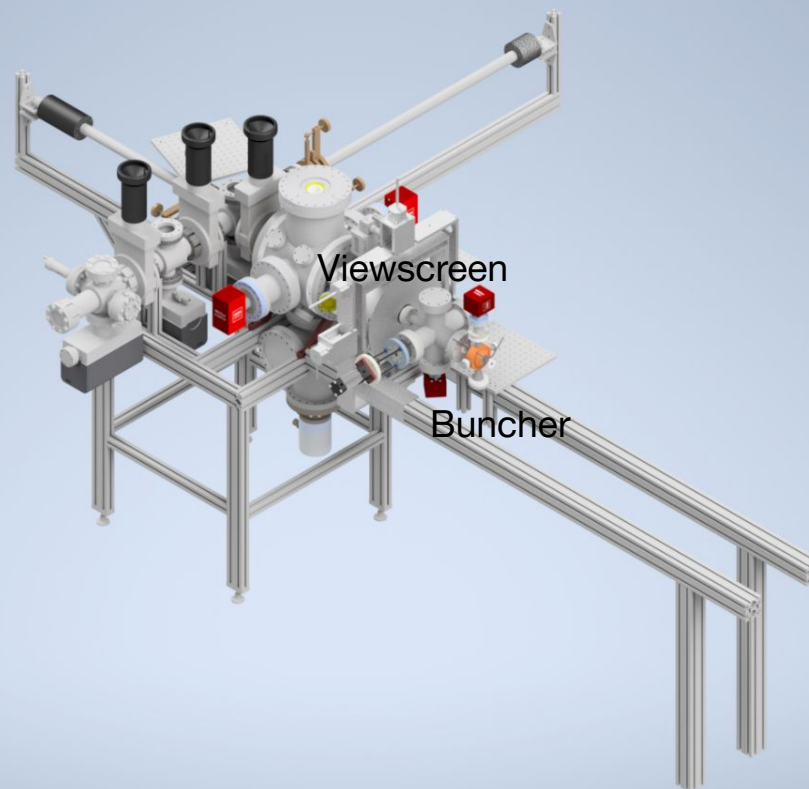


Beamline overview



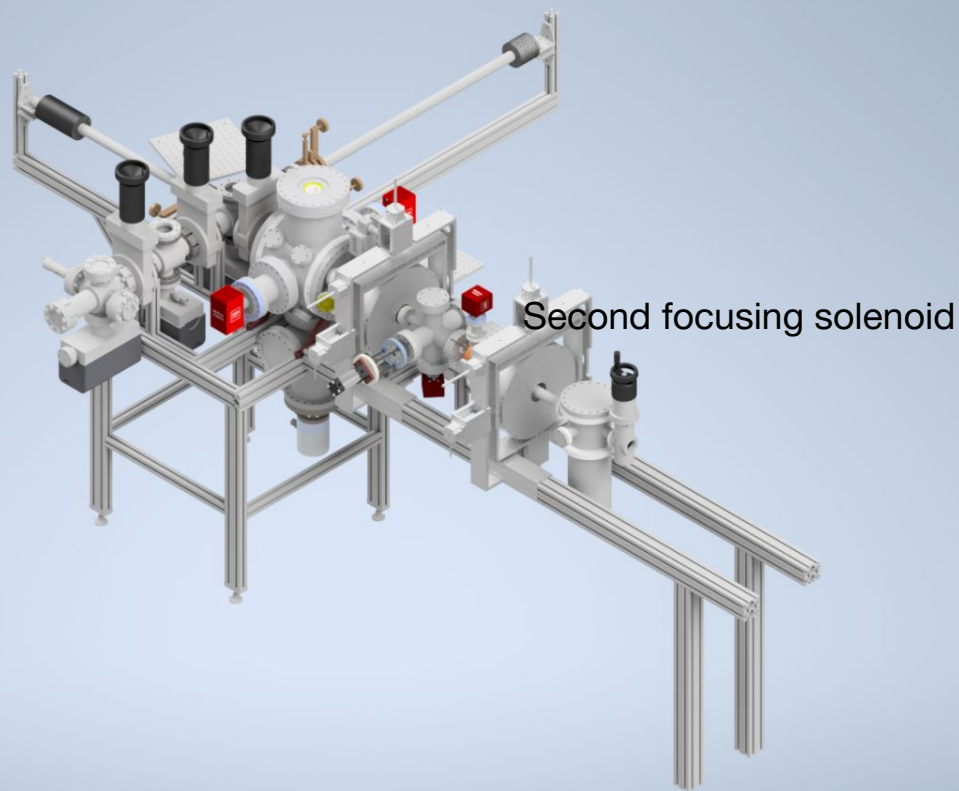


Beamline overview



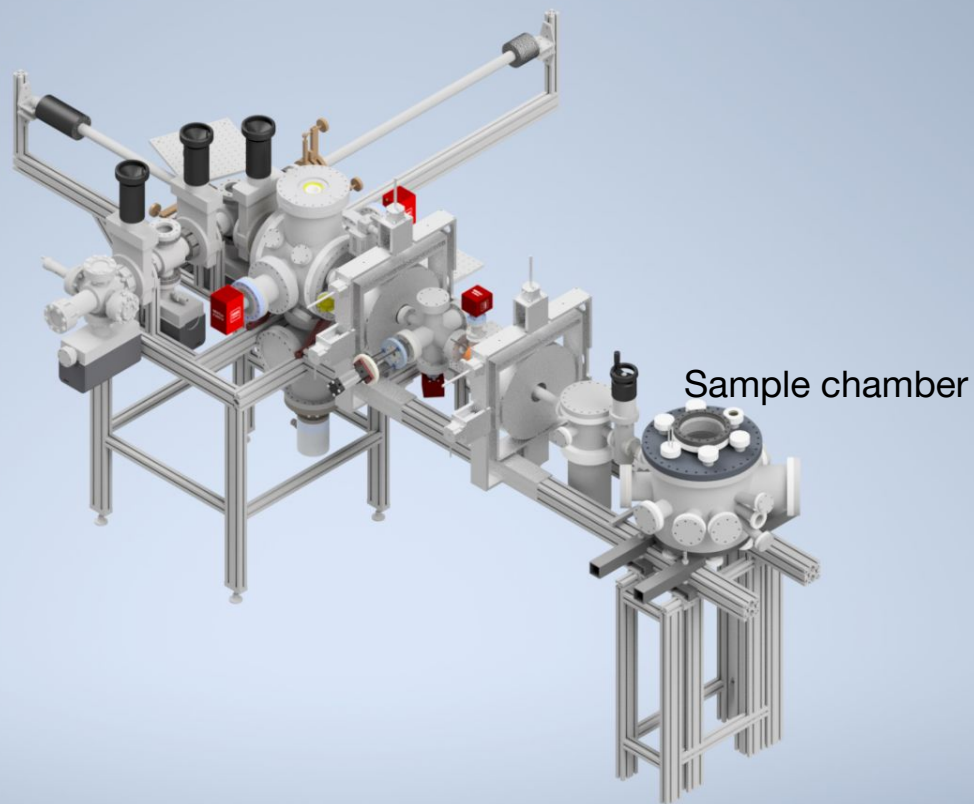


Beamline overview



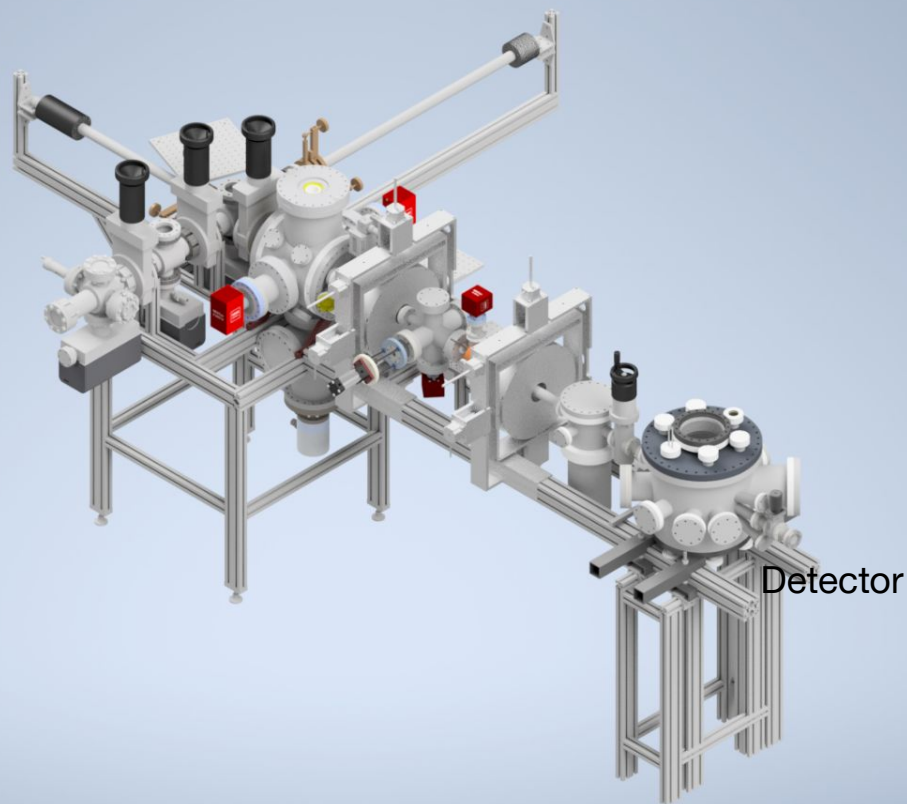


Beamline overview



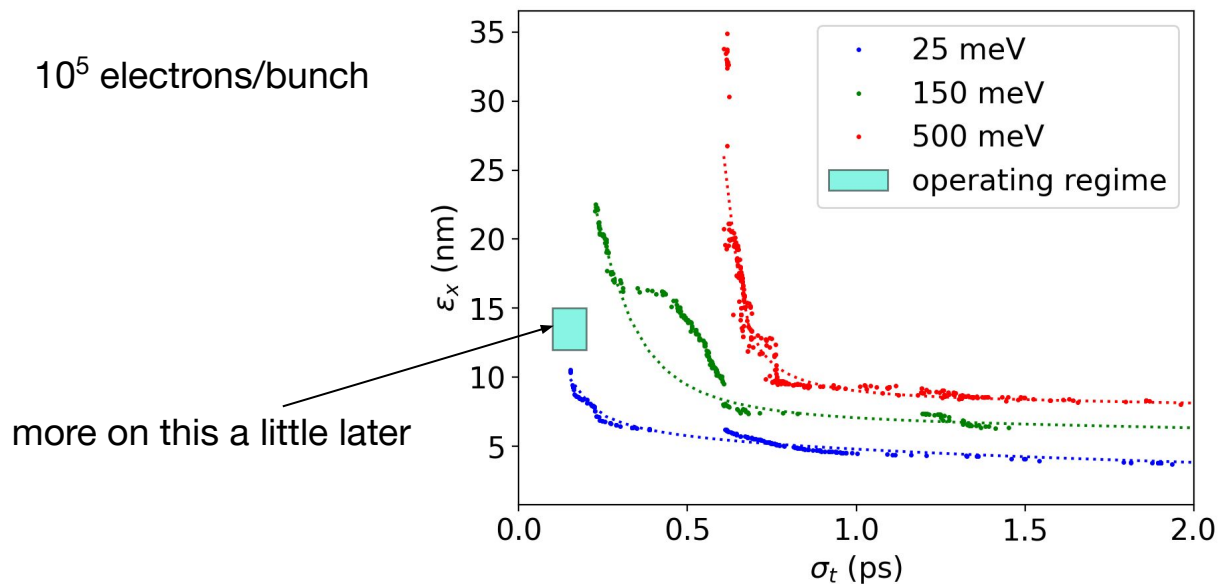
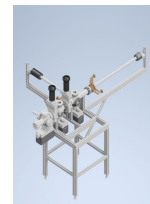


Beamline overview





- Na-K-Sb cathode grown at Cornell
- These cathodes have previously been measured to have high (percent-level) QE in the green and low (~ 35 meV) MTE at threshold
 - In simulation, decreasing MTE has a noticeable effect on emittance at the sample, around a factor of 2 at sub-picosecond bunches





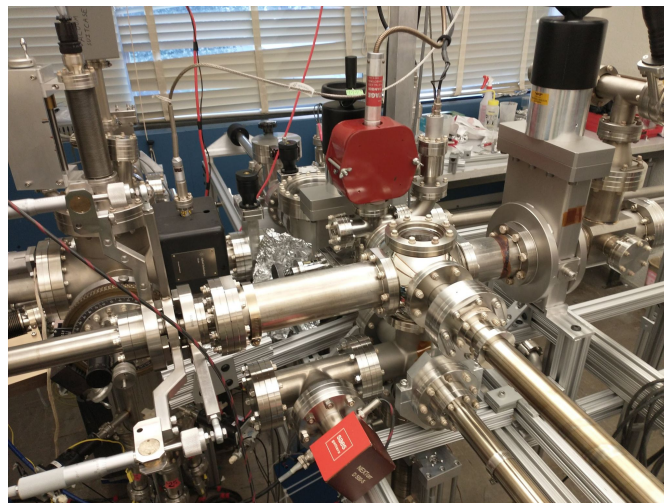
Cathode transfer

- The vacuum in all components of the cathode transfer process is kept under 10^{-10} Torr
- Compact suitcase fits inside the beamline's lead shielding
- Our Na-K-Sb photocathodes retain QEs in the 10^{-4} level at 650 nm after transfer to the gun

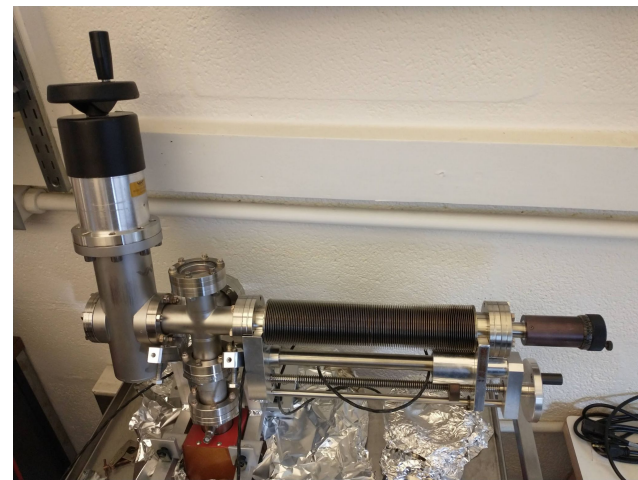
Cathodes grown on INFN/DESY/LBNL style miniplug



Suitcase attachment



Growth chamber

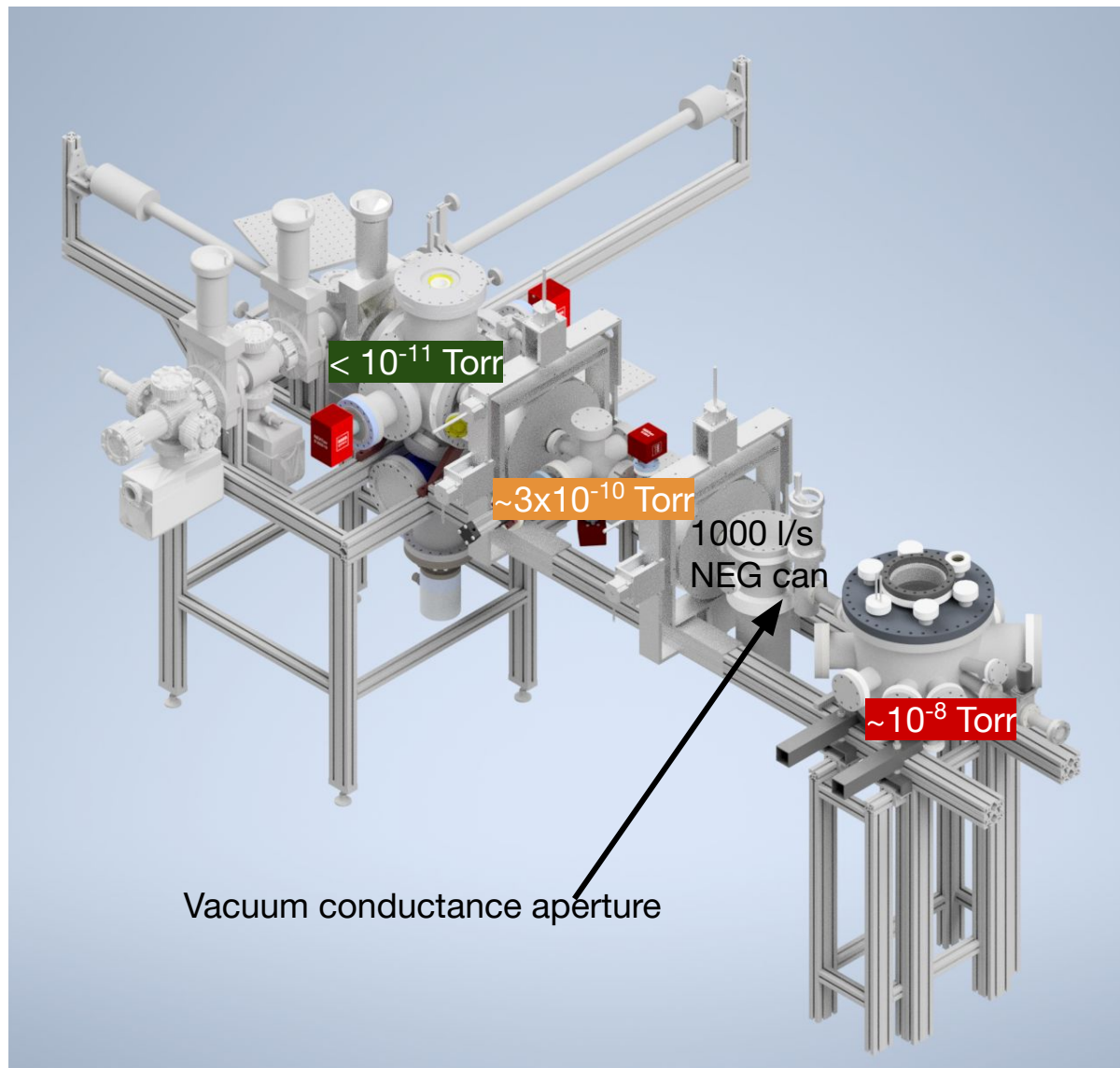


Vacuum suitcase



Vacuum

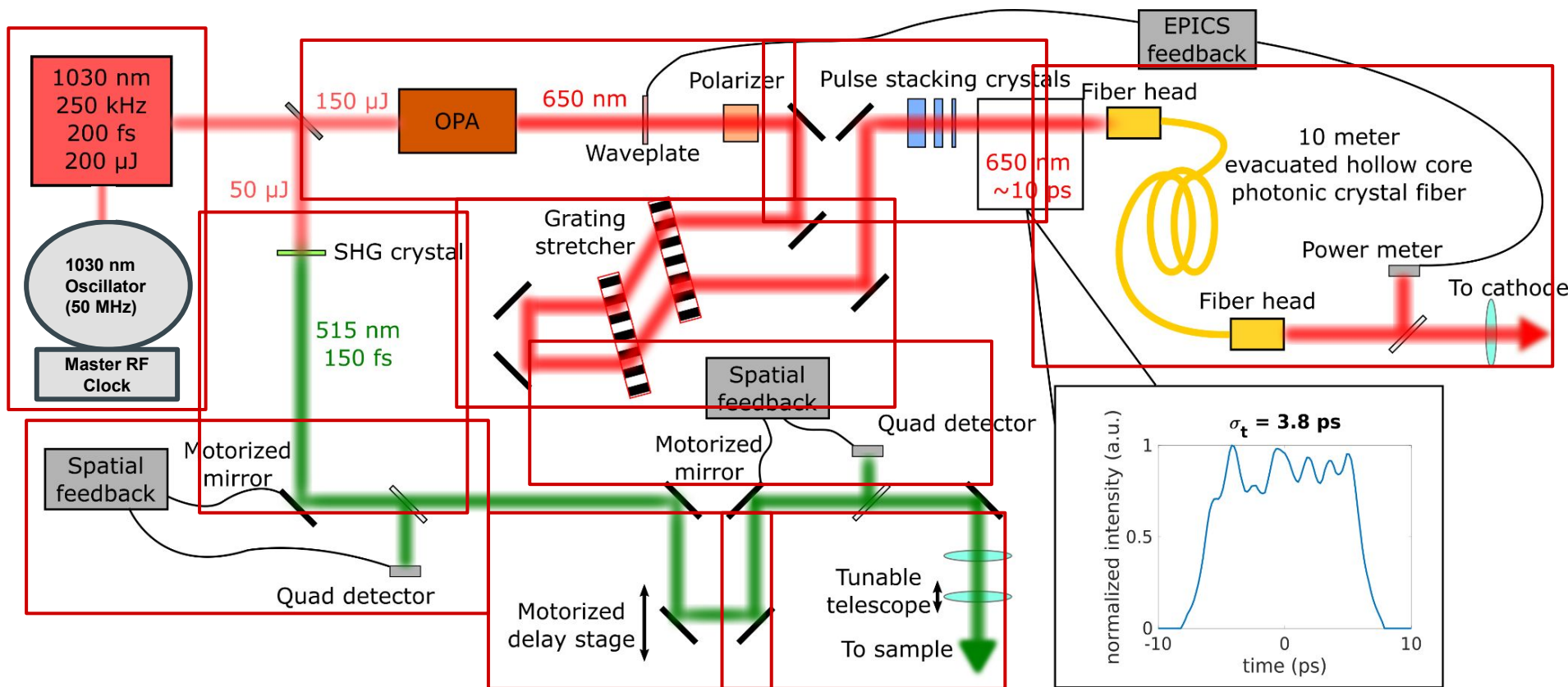
- Baking out sample chamber is impractical
- Conductance aperture and NEG can between sample chamber and beamline
- Gun remains below 10^{-11} Torr even with the sample chamber at 10^{-8} Torr.
- We've been able to use same photocathode for >800 hours of runtime





Laser setup

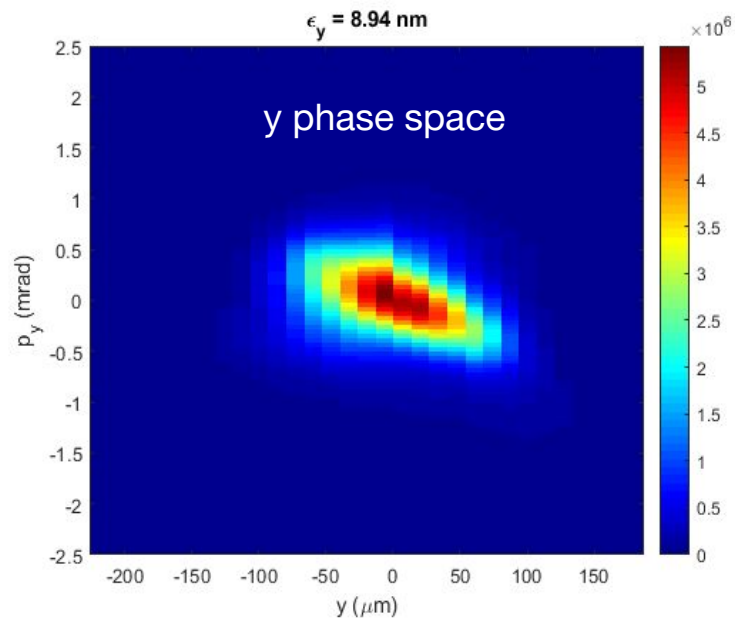
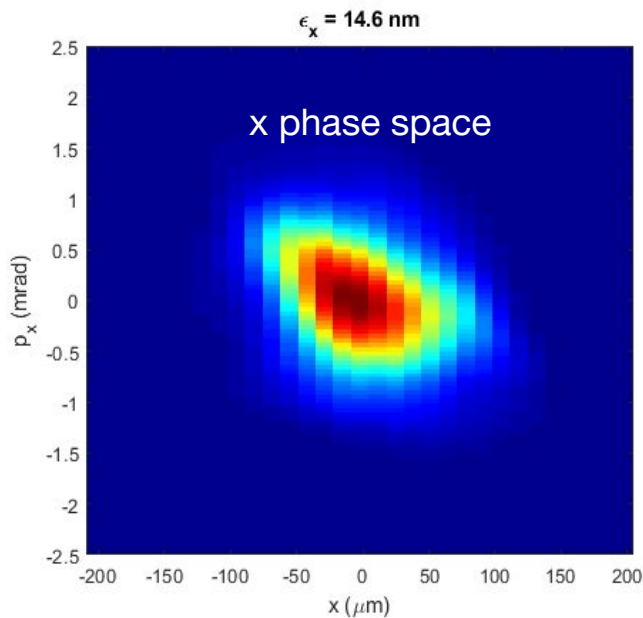
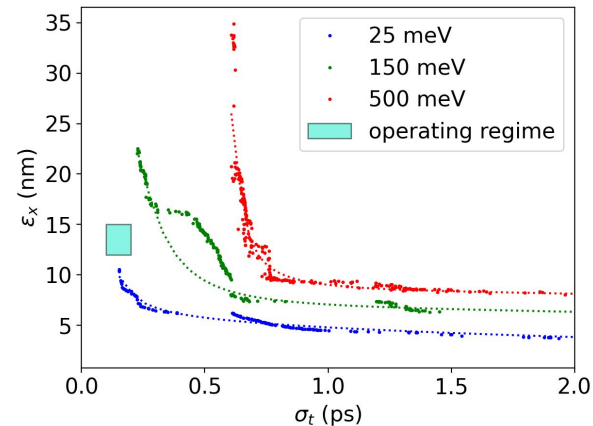
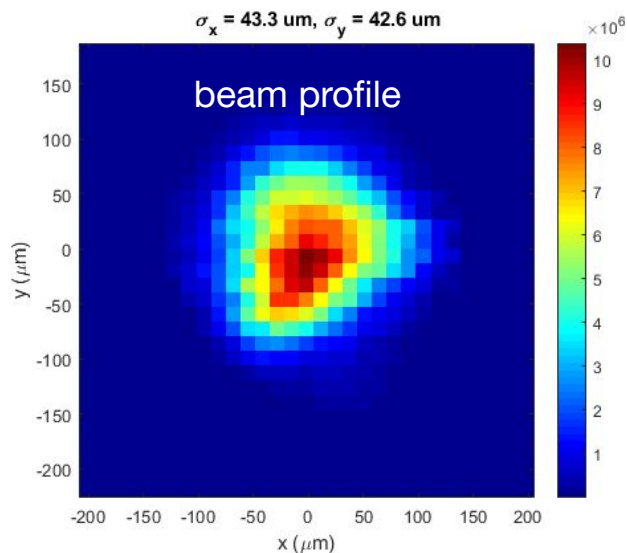
- We split a 1030 nm seed, generating 515 nm light for the pump and 650 nm light for the cathode
- 650 nm is chosen as it is near threshold but remains in the linear photoemission regime





Emittance

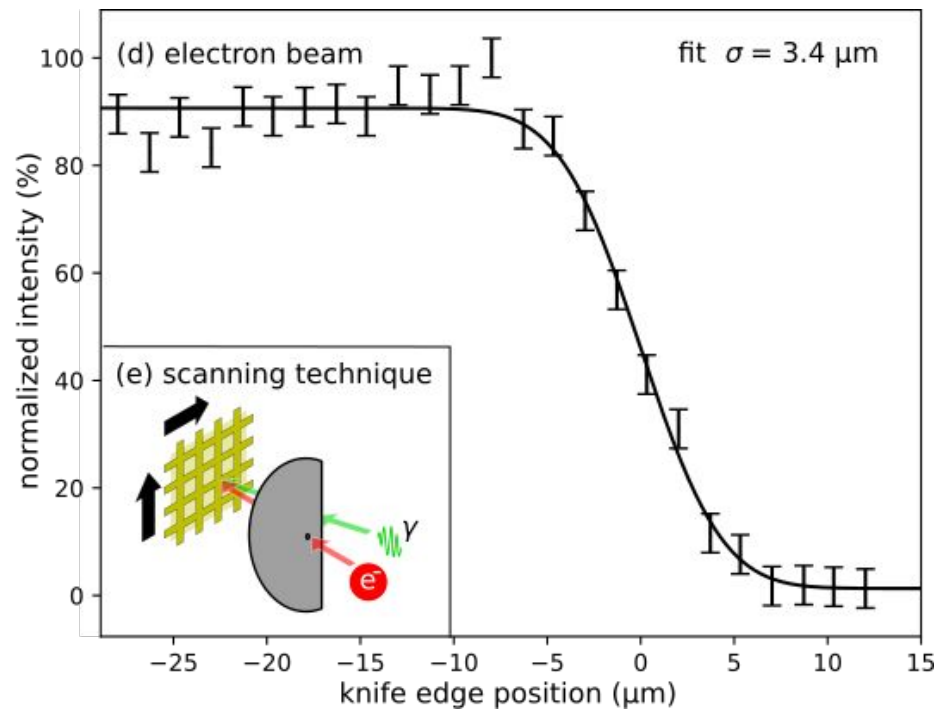
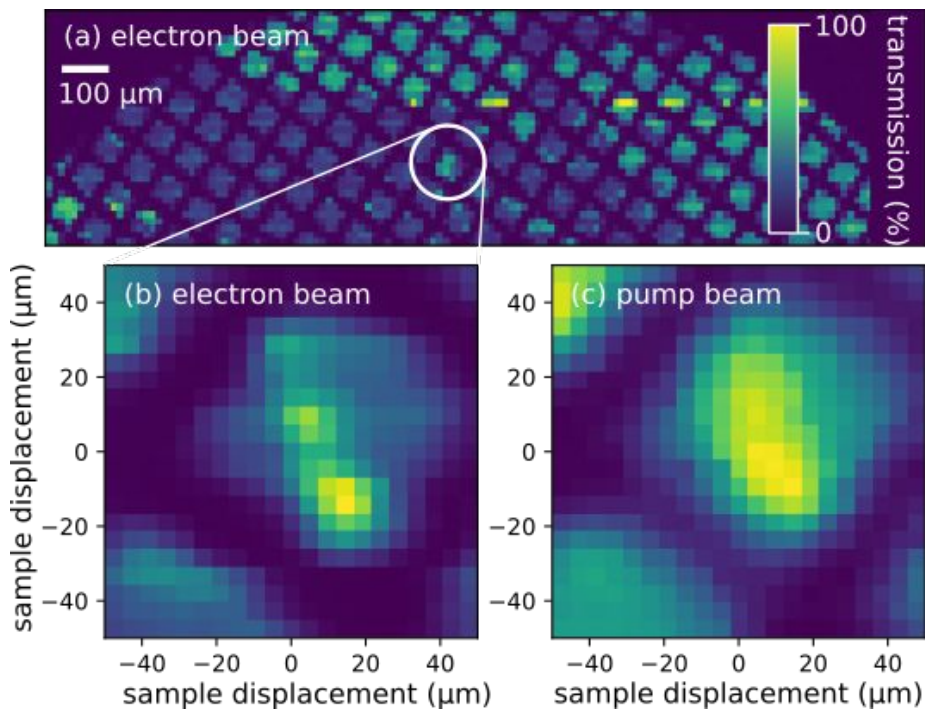
- We can measure the emittance at the sample plane with a knife edge
- <15 nm normalized emittance in x
- 9 nm normalized emittance in y
- Right in the blue rectangle





Spatial resolution

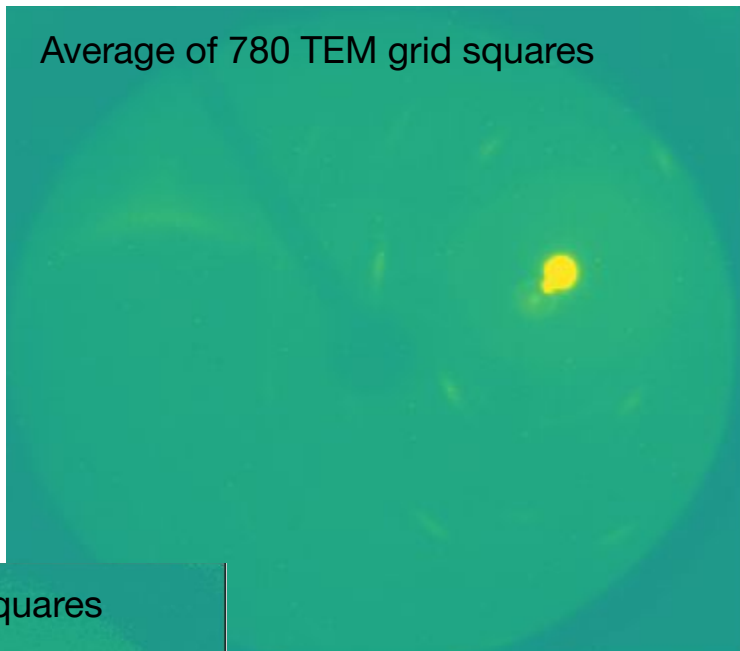
- 10 μm aperture placed just before sample (~ 500 electrons through)
- We characterize the size of the electron beam in two different ways
 1. TEM grid scan (a)-(c)
 - a. Also gives us spatial overlap with pump beam
 2. Direct knife edge scan (d)



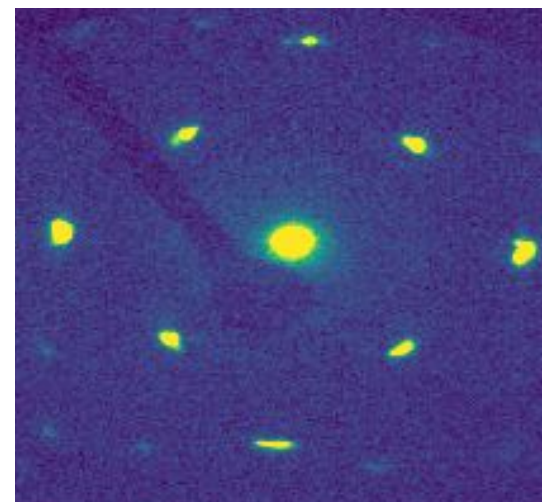
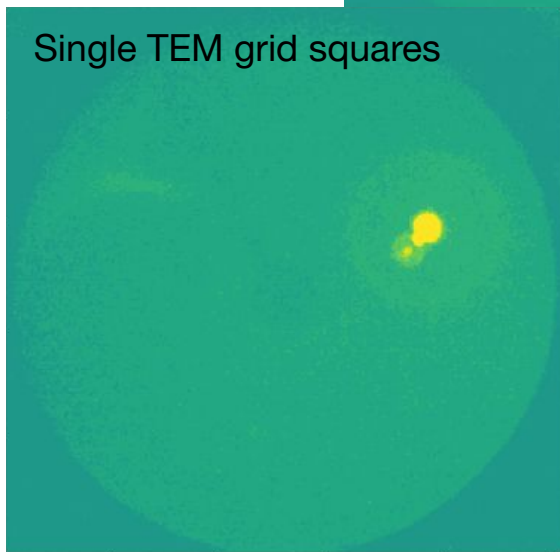


Spatial resolution

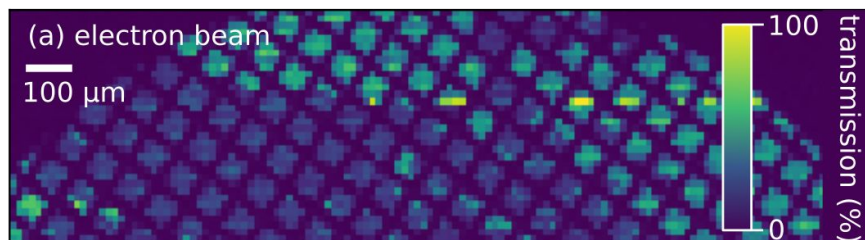
Average of 780 TEM grid squares



Single TEM grid squares



Single TEM grid square



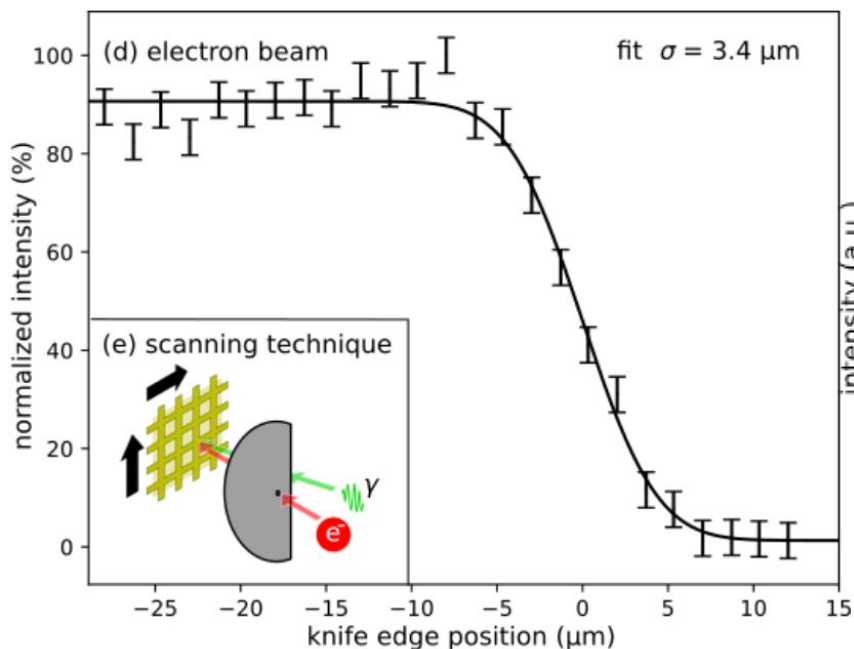
Transmission scan of TEM grid



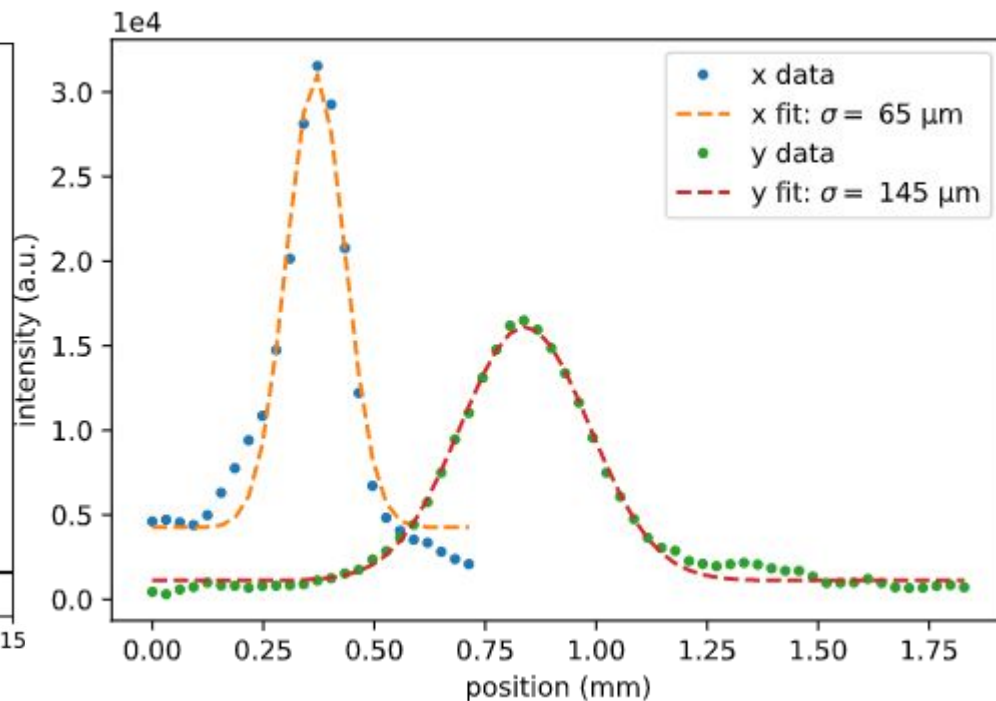
Emittance (apertured)

- At waist, $\varepsilon = \sigma_x \sigma_{x'}$
- For the ~ 500 electrons passing through aperture:
0.7 nm normalized emittance!

Size measured with knife edge



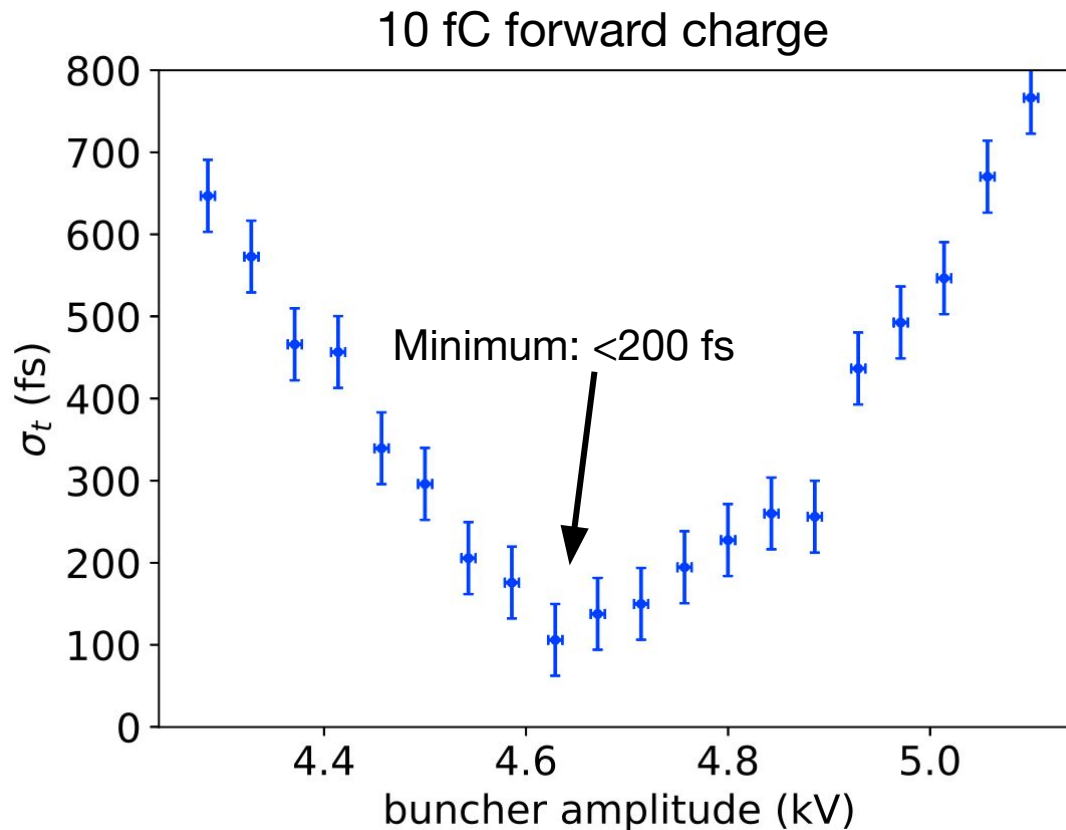
Momentum spread measured with size on final screen





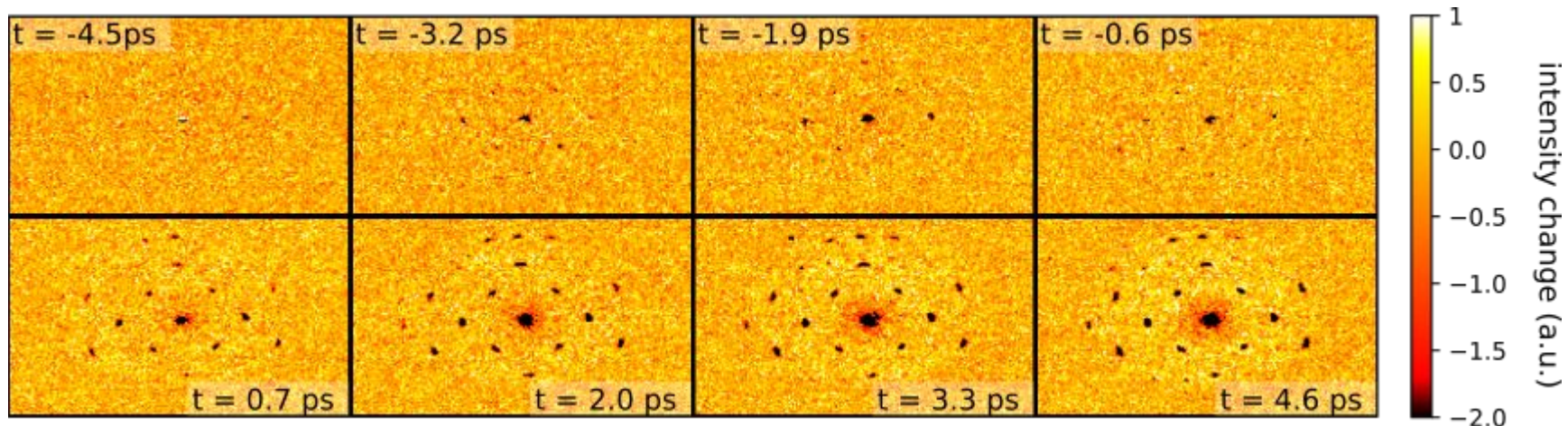
Bunch length

- The bunch length can be obtained by measuring the beam size along an rf deflection axis.





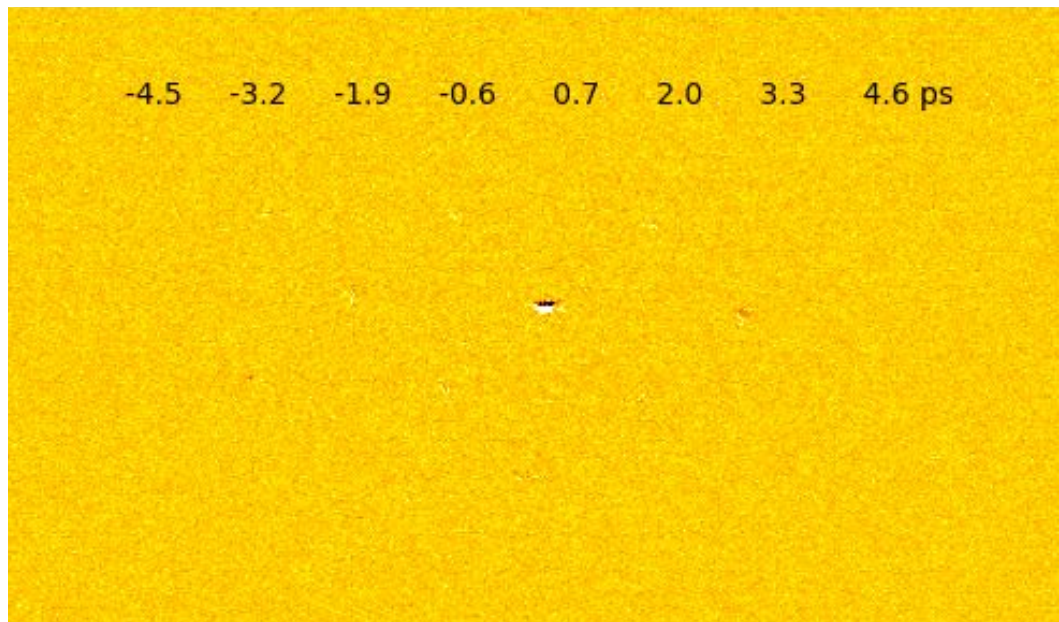
Gold UED



Signal S is the *relative* change in intensity I :

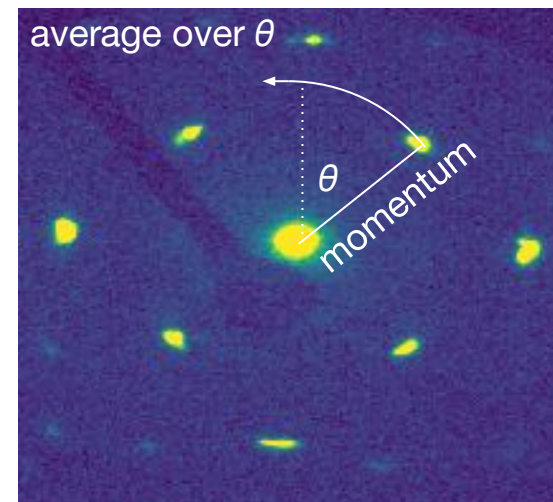
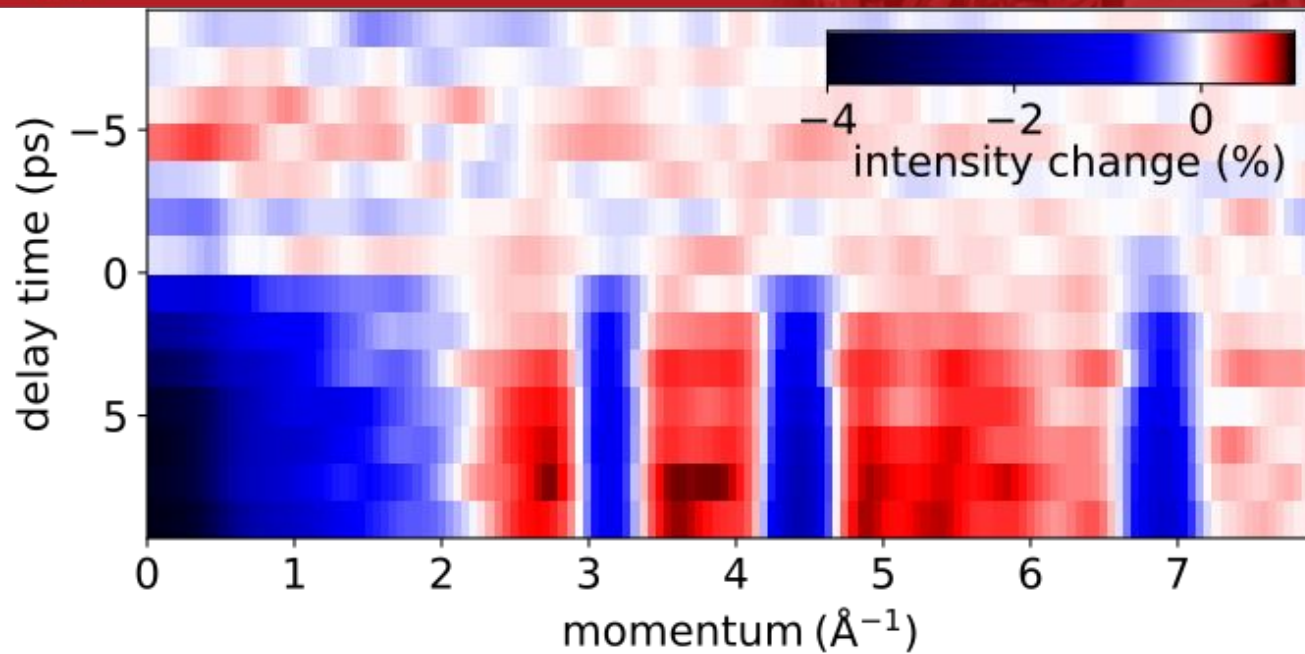
$$S = \frac{I_{\text{hot}} - I_{\text{cold}}}{I_{\text{cold}}}$$

In our experiment, $|S| \sim 1\%$



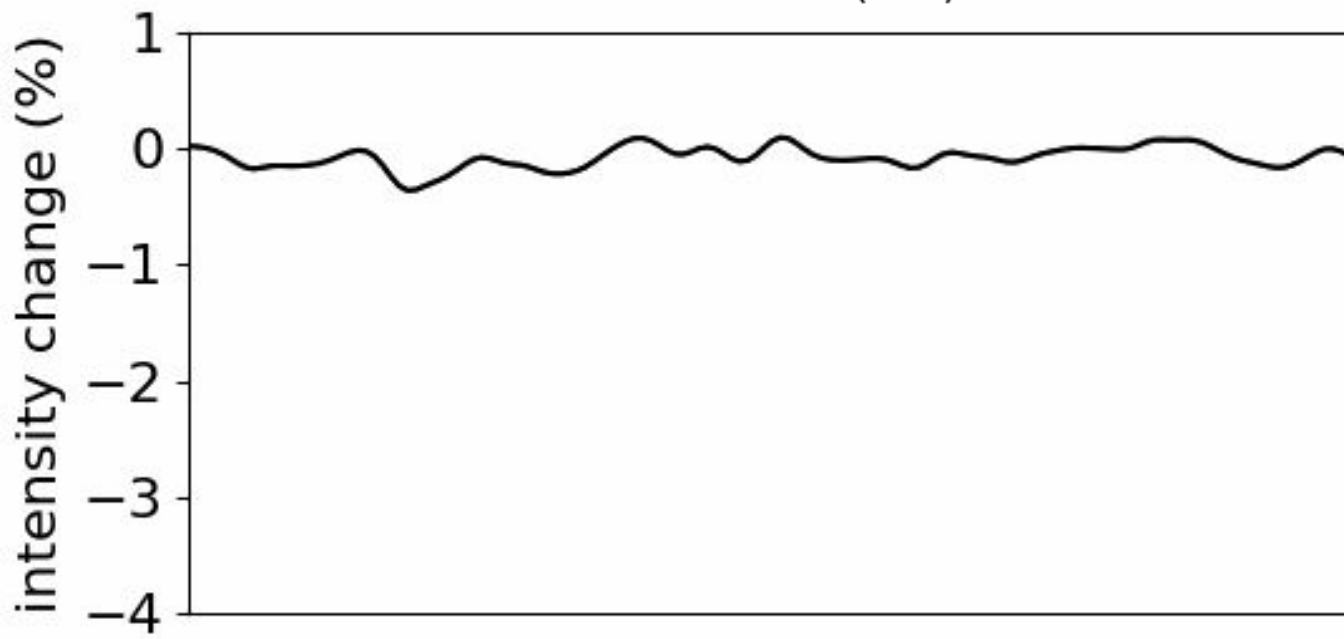
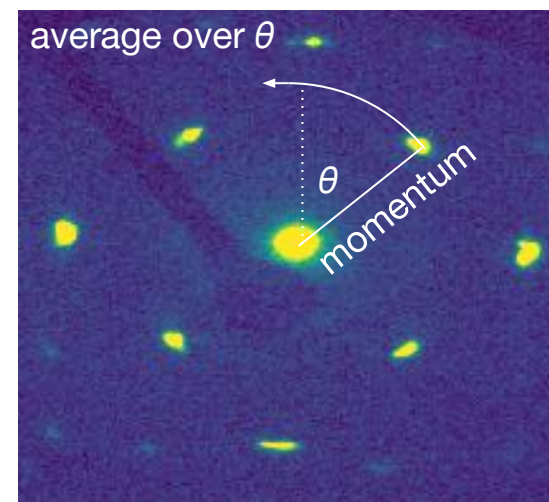
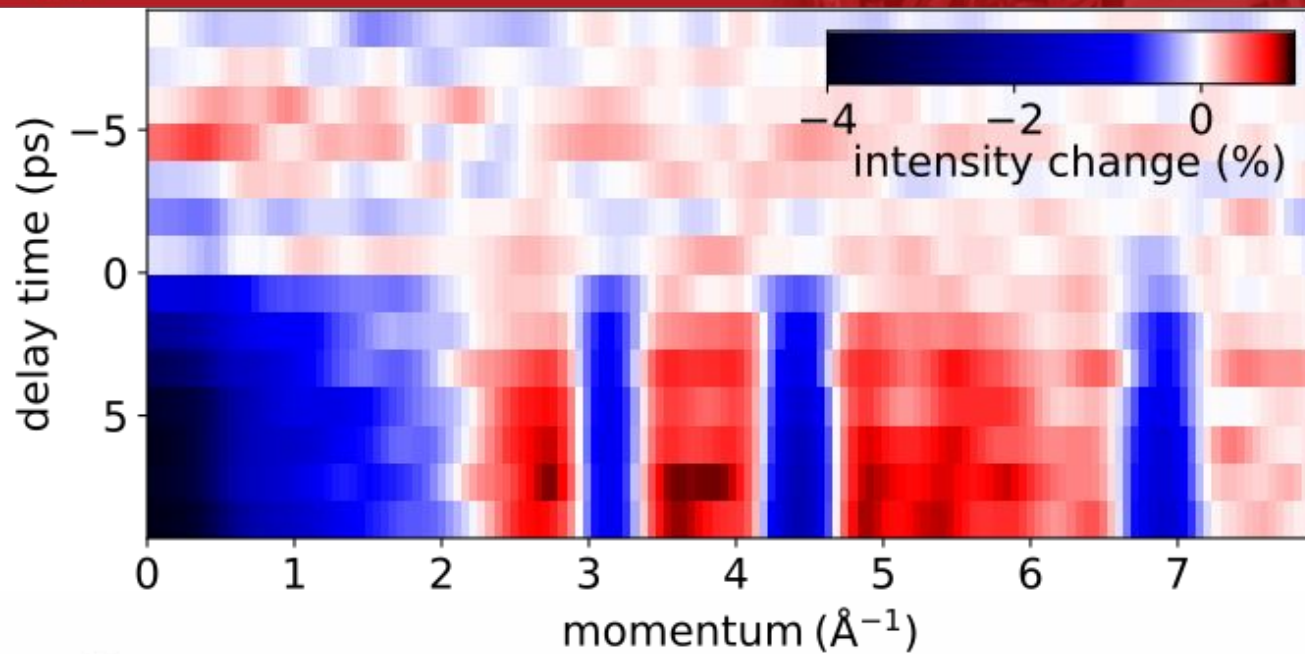


Gold UED



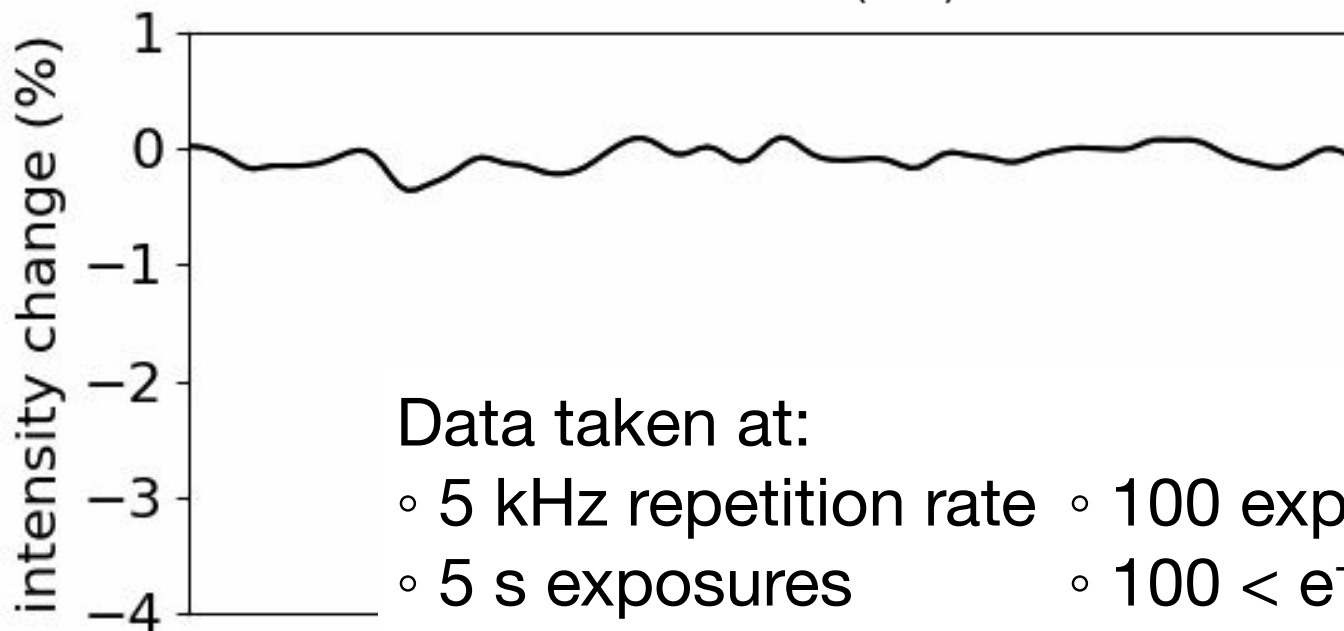
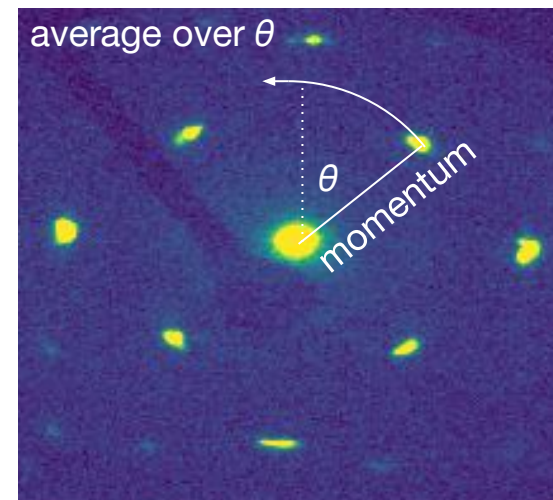
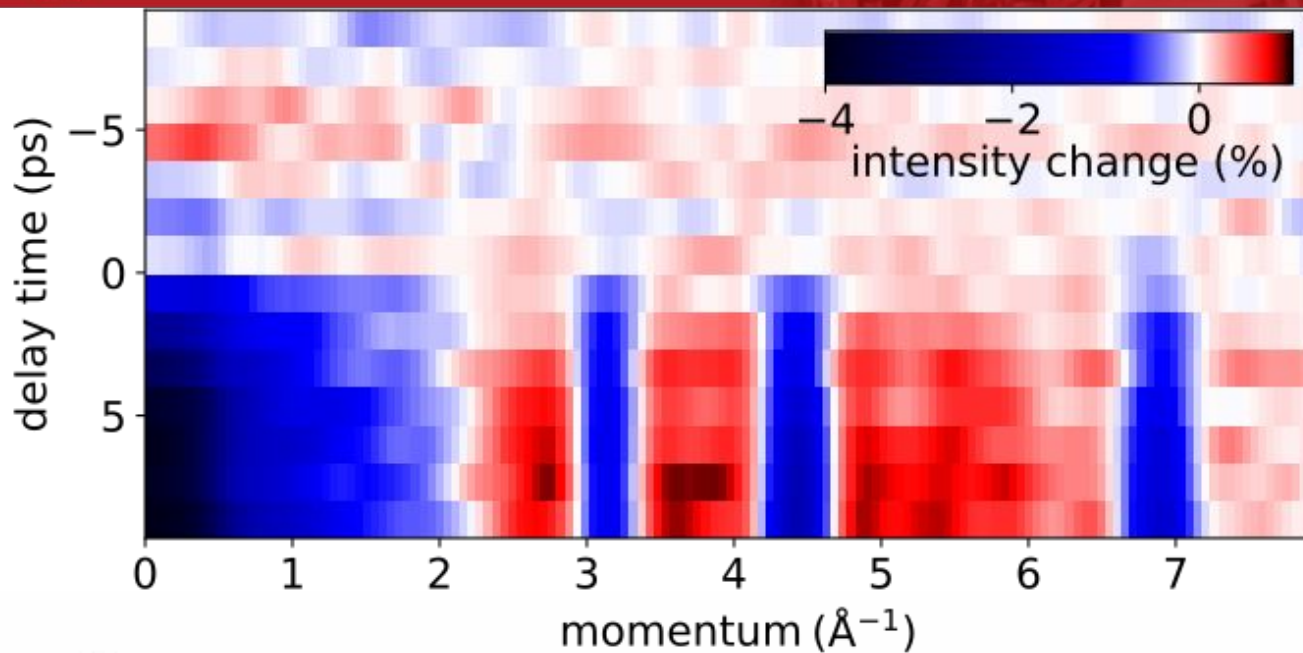


Gold UED





Gold UED



Data taken at:

- 5 kHz repetition rate
- 100 exposures per delay
- 5 s exposures
- $100 < e^- \text{ per shot} < 1000$

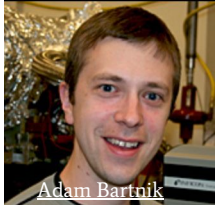


Acknowledgements

Maxson Group



Jared Maxson



Adam Bartnik



Chad Pennington



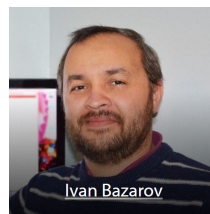
Mike Kaemingk



Alice Galdi

Now at U. Salerno.

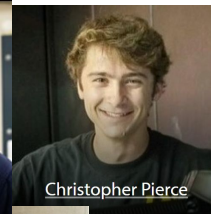
Bazarov Group



Ivan Bazarov



Matthew Andorf



Christopher Pierce



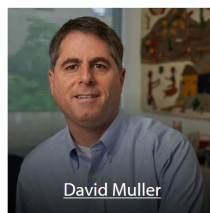
Luca Cultrera

Now at BNL

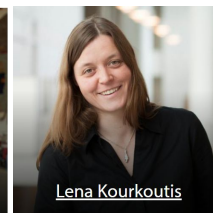


Jai Kwan Bae

Cornell Electron Microscopy

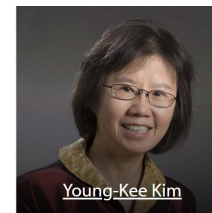


David Muller



Lena Kourkoutis

U. Chicago Beam Dynamics



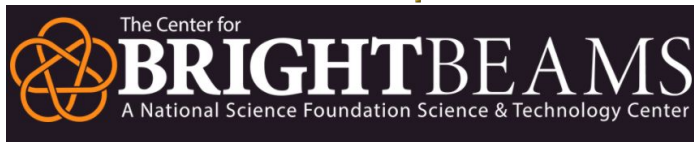
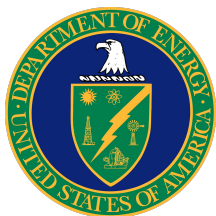
Young-Kee Kim



Matthew Gordon



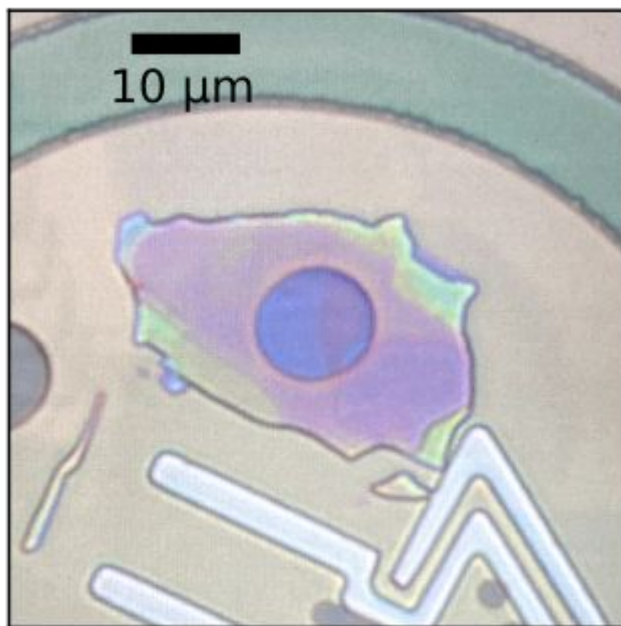
Elisabeth Blanco





Conclusion

- MEDUSA is an operational UED beamline running low MTE Na-K-Sb photocathodes at threshold, in the linear photoemission regime
- Low MTE enables subpicosecond, micron scale bunches with hundreds of electrons per bunch and fine reciprocal space resolution



Diffraction sample, Nb_3Br_8

